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|-----------------------------------|---------------------------------------|--|---|-------------|
| Notice of References Cited | Application/Control No. 09/455,102 | | Applicant(s)/Patent Under Reexamination PERSSON ET AL. | |
| | Examiner Daniel S. Metzmaier | | Art Unit 1712 | Page 1 of 1 |

U.S. PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Name | Classification |
|---|---|--|-----------------|--------------------------|----------------|
| * | A | US-2003/0024671 | 02-2003 | Persson et al. | 162/181.6 |
| * | B | US-6,673,208 | 01-2004 | Persson et al. | 162/181.6 |
| * | C | US-5,116,418 | 05-1992 | Kaliski, Adam F. | 106/419 |
| * | D | US-2,750,345 | 06-1956 | ALEXANDER GUY B | 516/83 |
| * | E | US-2,727,008 | 12-1955 | ILER RALPH K | 516/83 |
| * | F | US-2,601,235 | 06-1952 | ALEXANDER GUY B; et. al. | 516/82 |
| | G | US- | | | |
| | H | US- | | | |
| | I | US- | | | |
| | J | US- | | | |
| | K | US- | | | |
| | L | US- | | | |
| | M | US- | | | |

FOREIGN PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Country | Name | Classification |
|---|---|--|-----------------|---------|------|----------------|
| | N | | | | | |
| | O | | | | | |
| | P | | | | | |
| | Q | | | | | |
| | R | | | | | |
| | S | | | | | |
| | T | | | | | |

NON-PATENT DOCUMENTS

| * | | Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages) |
|---|---|--|
| | U | MSDS, J.T.Baker online @ www.jtbaker.com/msds/englishhtml/s4982.htm , pages 1-7, printed 4/24/2006 |
| | V | Iler, The Colloid Chemistry of Silica and Silicates, Cornell University Press, Ithica, NY (07-1955), pages 20-21 & 26-27. |
| | W | Hackh's Chemical Dictionary, edited by Julius Grant, McGraw-Hill Book Co, NY, NY, copyright 1972 (received 12-1979), page 610, silicate entry. |
| | X | |

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.